	Application No.	Applicant(s)	
Notice of Allowability	10/085,759	COTE ET AL.	
	Examiner	Art Unit	
	Stephen Rosasco	1756	*********
The MAILING DATE of this communication application application application and All claims being allowable, PROSECUTION ON THE MERITS herewith (or previously mailed), a Notice of Allowance (PTOLNOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT of the Office or upon petition by the applicant. See 37 CFR 1.	IS (OR REMAINS) CLOSED (85) or other appropriate commor RIGHTS. This application is	n this application. If not included unication will be mailed in due co	ourse. THIS
1. This communication is responsive to <u>12/8/03</u> .			
2. The allowed claim(s) is/are <u>1-9 and 33-50</u> .			
3. \boxtimes The drawings filed on <u>28 February 2002</u> are accepted to	by the Examiner.		
4. ☐ Acknowledgment is made of a claim for foreign priority a) ☐ All b) ☐ Some* c) ☐ None of the: 1. ☐ Certified copies of the priority documents h 2. ☐ Certified copies of the priority documents h 3. ☐ Copies of the certified copies of the priority International Bureau (PCT Rule 17.2(a)). * Certified copies not received:	lave been received. lave been received in Applicati	on No	on from the
Applicant has THREE MONTHS FROM THE "MAILING DAT noted below. Failure to timely comply will result in ABANDC THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		e a reply complying with the requ	irements
5. A SUBSTITUTE OATH OR DECLARATION must be su INFORMAL PATENT APPLICATION (PTO-152) which			TICE OF
6. CORRECTED DRAWINGS (as "replacement sheets") (a) including changes required by the Notice of Draftspan 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examin Paper No./Mail Date	person's Patent Drawing Revie		/
Identifying indicia such as the application number (see 37 CF each sheet. Replacement sheet(s) should be labeled as such			ack) of
7. DEPOSIT OF and/or INFORMATION about the deattached Examiner's comment regarding REQUIREME			te the
Attachment(s) 1. ☑ Notice of References Cited (PTO-892)	5. ☐ Notice of I	nformal Patent Application (PTO-	152)
Notice of Draftperson's Patent Drawing Review (PTO-94)		Summary (PTO-413),	,
3. ☑ Information Disclosure Statements (PTO-1449 or PTO/S Paper No./Mail Date 10/6/03	SB/08), 7. ☐ Examiner's	/Mail Dates Amendment/Comment	vanaa.
 Examiner's Comment Regarding Requirement for Deposit of Biological Material 	sit 8. ⊠ Examiner: 9. ☐ Other	s Statement of Reasons for Allow	aille
			

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ALLOWANCE ACTION

In response to the Amendment of 12/8/03, wherein applicant elected the claims of Group I, canceled claims 10-32 and added claims 33-50, the examiner allows all pending claims 1-9 and 33-50.

The following is an examiner's statement of reasons for allowance: the claimed invention is distinguished over the prior art of record in that the prior art does not teach a method for manufacturing an integrated circuit having a layer of material, the layer described by a layout, wherein substantially all of the layer of material will be defined using phase shifting, the method comprising:

identifying a plurality of features in the layout to be defined using phase shifting, each of the plurality of features comprised of a plurality of edges;

placing a plurality of shifter shapes proximate to edges of the plurality of features, wherein the plurality of features includes a first feature having a first edge and a second edge, the first edge adjoining the second edge, and wherein the plurality of slûûer shapes

placed on a second edge, the first shifter shape and the second shifter shape separated by a minimum distance;

assigning phase to the plurality of shifter shapes according to phase dependencies and costs to create a plurality of phase shifters; and refining the plurality of phase shifters.

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Watanabe (6,400,838) teach the method of

- a) a developing design data used to delineate patterns on a sample into gradational data expressed in non-binary, multiple gradation levels having a maximum level of 4n, where n is a positive integer equal to or larger than one;
- (b) finely adjusting edges of the patterns by a process employing the gradational data expressed in the non-binary multiple gradation levels and generating reference data, wherein the finely adjusting step modifies a size of the patterns by changing edge positions of the patterns constructed with the gradational data;
- (c) generating measured data from actual patterns delineated on the sample; and
- (d) comparing the measured data with the reference data and the edges of the pattern of the reference data being adjusted by the finely adjusting step, wherein the finely adjusting step includes a corner rounding step of rounding corners in the pattern constructed with the gradational data, the corner rounding step including the steps of: converting the gradational data into binary data;

detecting corners in the pattern constructed with the gradational data according to the binary data;

deciding the size of each of the corners according to the binary data;

generating rounding data for the corners according to information provided by the deciding step; and

rounding the corners according to the rounding data and gradational data.

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Watanabe also teaches that making the size of a pixel of the developed pattern data smaller than a sensor pixel size to adjust the pattern data to match with the microscopically displaced edges and rounded corners of the actual photomask patterns increases the quantity of the pattern data to raise a need of high-performance computers and high costs.

Watanabe does not teach the details of placement of the shifter shapes as recited in the claimed invention including the above cited limitations.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Stephen Rosasco whose telephone number is 571-272-1389. The examiner can normally be reached on M-F from 9 to 5.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mark Huff, can be reached on 571-272-1385. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306. General Information call (571-272-1700).

S. Rosasco Primary Examiner Art Unit 1756

S.Rosasco 2/5/04